SMART NanoTool PLD

Versatile Research Pulsed Laser Deposition



SMART NanoTool PLD

- SVT Associates SMART (Scientific Materials and Applied Research Tool) Pulsed Laser Deposition System is a unique research tool. Combining Laser Ablation with our unique deposition techniques offers a broad range of possible materials and applications.
- A multitude of thin film structures are possible utilizing six rotational targets that are individually indexed.
- Optional in-situ monitoring tools provide the user with enhanced process feedback.
- Interfaces with Excimer and YAG Lasers.
- Available load lock sample handling allows the SMART system to interface with other deposition or metrology tools.

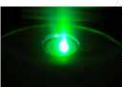
SVT Associates, Inc.

- Leading manufacturer of thin film deposition equipment since 1993
- In-house laboratory for materials research and process development
- Established a diverse range of deposition components, systems, integrated sensors, and process control
- Developed strong combination of equipment manufacturing and process know-how
- Seven Applications Laboratory deposition systems producing world class materials
- Diverse system product line spanning the thin film deposition market
- Leading supplier with over 190 systems in the field

Applications

- Multiple Component Complex Oxides
- High Temperature Superconductors
- Magnetic and Metallic Material Deposition
- Low Vapor Pressure Materials
- MEMS









SMART NanoTool PLD-01

BASE SYSTEM

Chamber and Vacuum Pumps

12" Quick Access Door, 300l/s Turbo Pump Full Range Vacuum Gauges

Deposition Sources

Target Stage, Six 1" (25 mm) Targets with Indexing, Rotation and

z-Direction Translation

Deposition Stage

1" (25.4 mm) Sample Size, Heating to 800 C, Continuous Rotation, z-Direction Translation

In-Situ Process Monitoring Tools

Quartz Crystal Deposition Rate Monitor

AUTOMATION

Automation Package:

Control Sample Temperature and Rotation

Indexed Target Position

Target Rotation

Gas Control

Compute Rate & Thickness using QCM Output

Laser Beam Scanning (optional)

Laser Interface for Beam Blanking

Automated Pumpdown and Venting

Differential Pumping

RHEED Analysis (optional)

Load Lock Pressure Monitoring (optional)

AVAILABLE OPTIONS:

Deposition Sources

Thermal Evaporation Sources, Effusion Cells, Sputter Sources, E-Beam Evaporators, RF Plasma Sources

Deposition Stages

Multiple Options Up to 2" Sample Size

Metrology Tools

10kV to 30kV RHEED Packages

Vacuum Packages

Ion Pumps, Turbo Pumps, Cryo Pumps, Gate Valves

Gauge Packages

Multiple Gauge Packages Available

Gas Control Packages

Mass Flow and Leak Valve Packages
Upstream and Downstream Throttling Control

Loadlock Package

Loadlock, Docking and Transfer Configurations

Ultra High Vacuum

Differential Pumping and System Bakeout Options Available

